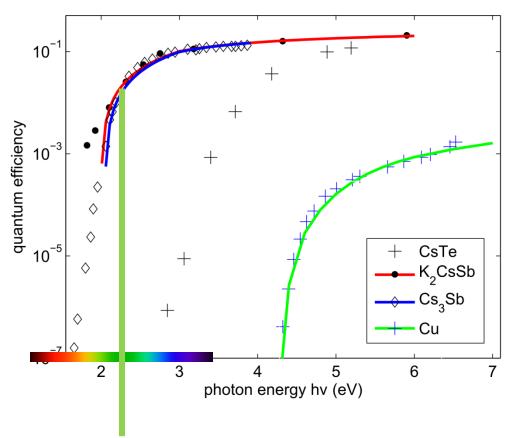


CsK₂Sb PHOTOCATHODE DEVELOPMENT FOR 1 bERLinPro

Martin Schmeißer, Julius Kühn, Thorsten Kamps, Andreas Jankowiak Helmholtz-Zentrum Berlin





532nm available as 2. harmonic of Nd or Yb lasers

Photoinjector for bERLinPro

Aim:

- 0.5 mm mrad emittance from gun
- 100mA in cw operation
- 2ps rms bunch length

Boundary conditions

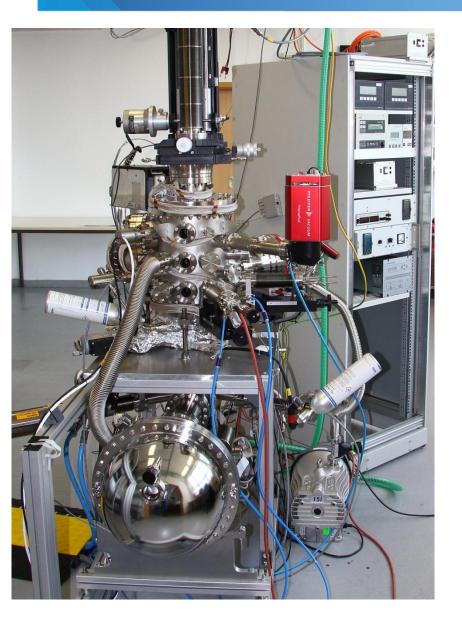
 1% QE at 532nm requires 23W average laser power on the cathode

$$P_{\text{laser}} = \frac{124 \,\text{W nm}}{\lambda \cdot OE}$$

 High-QE semiconductors are highly reactive, survive only in 10⁻¹⁰ mbar vacuum

PHOTOCATHODES





Preparation chamber:

- effusion cell for Sb, dispenser sources for K and Cs
- co-deposition of K and Cs or K and Sb

Quantum efficiency:

- Spectral response
- Spatial distribution

Intrinsic Emittance:

Resolved in a drift-space spectrometer - Momentatron

See IPAC14 mopri019

Surface Analysis chamber:

- X-ray photoelectron spectroscopy (XPS)
- Low Energy Ion Scattering (LEIS)

Now commissioned and ready for experiments:

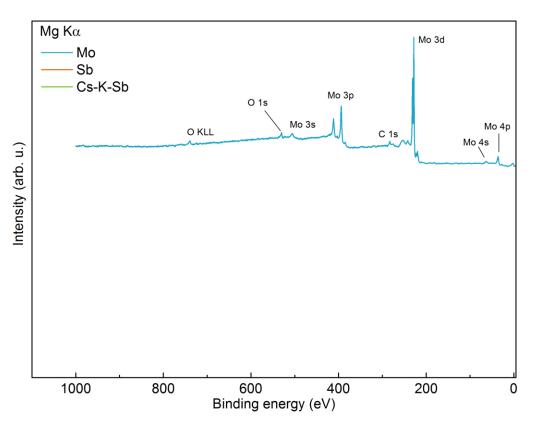
- First Sample in April '15
- XPS system calibrated
- Both chambers in 10⁻¹⁰ mbar UHV

PHOTOCATHODES - FIRST SAMPLE



Sequential growth recipe

- Mo substrate, annealed at 450°C for 1h, sputter cleaned with Ar+, 3kV for 30min
- Substrate is relatively clean, O and C impurities probably from the material (99.9%)

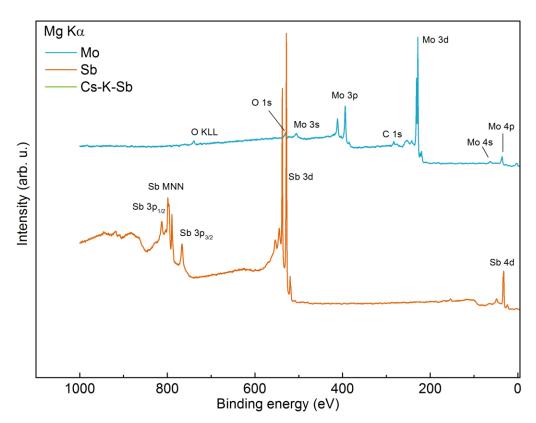


PHOTOCATHODES - FIRST SAMPLE



Sequential growth recipe

- Mo substrate, annealed at 450°C for 1h, sputter cleaned with Ar+, 3kV for 30min
- Substrate is relatively clean, O and C impurities probably from the material (99.9%)
- Sb deposition at 1*10⁻⁷ vapour pressure, 0.5 A/s
- Very clean Sb film



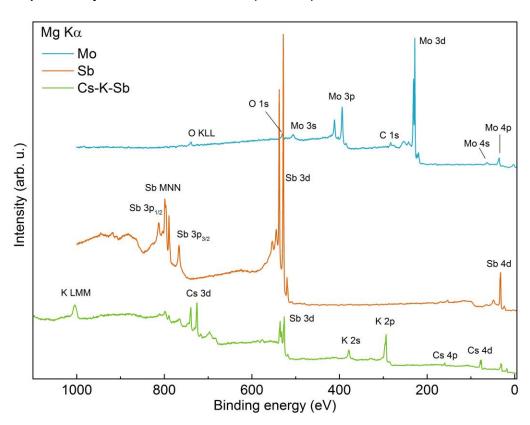
PHOTOCATHODES - FIRST SAMPLE



Sequential growth recipe

- Mo substrate, annealed at 450°C for 1h, sputter cleaned with Ar+, 3kV for 30min
- Substrate is relatively clean, O and C impurities probably from the material (99.9%)
- Sb deposition at 1*10⁻⁷ vapour pressure, 0.5 A/s
- Very clean Sb film
- K and Cs deposition from SAES dispensers
- Alkalis are hardly resolved in the mass spectrometer
- During K deposition, partial pressures of H₂0 2*10⁻⁹ mbar, O₂ and CO < 10⁻¹⁰
- Cs dispenser operated above its rated heating current to obtain a rate reading on quartz balance
- Cr and O impurities in the final Cs-K-Sb spectrum





QE: SPECTRAL RESPONSE MEASUREMENT



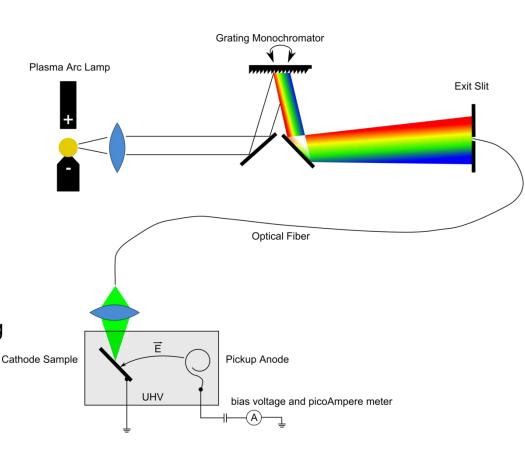
Requirements

- Broad band light source 400-700nm
- Spectral Intensity ~ 1µW / nm
- High spectral resolution < 1nm
- Sensitive current measurement
- 10 pA resolution, low noise

All commercially available, need to be set up carefully.

Probable solution:

300W Xe arc lamp
1/4m monochromator with 1200l/mm grating
Picoamperemeter, might need a lock in
amplifier + chopper wheel



PHOTOCATHODES



Next steps for cathode characterization:

- Polished Mo substrates: characterize surface quality
- Influence of annealing and sputtering on surface quality
- Optimize Alkali deposition
 - Closer working distance of dispensers
 - Characterize K and Cs films separately
 - Determine purity
 - Determine good working parameters
- CsK₂Sb growth
 - Characterize purity and composition
 - Determine growth parameters for stoichiometric deposition
 - Learn more on influence of deposition parameters and composition on electronic structure and emission properties
- Evaluate alkali deposition from alkali chromates in a large crucible
 - Electron beam evaporators available
 - Co-deposition and sensitive rate control should be possible

PHOTOCATHODES - TRANSFER SYSTEM



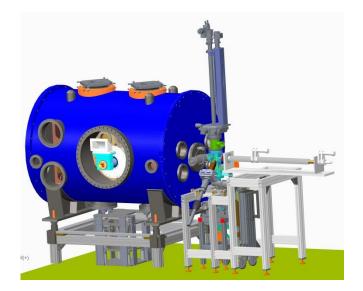
Cathodes must be stored and handled in 10⁻¹¹ mbar UHV!

- Vacuum suitcase is available. Vacuum ~ 1*10-11 mbar
- Stability with and without getter pump will be tested
- Design of plug holder is converged
- · Tests of thermal contact are ongoing
- Disc springs inside the holder rod are too stiff, will test with softer ones



- Transfer system 1 (at Prep chamber) is ordered, comissioning in fall `15
- Engineering Design : Petr Murcek, Kerstin Martin



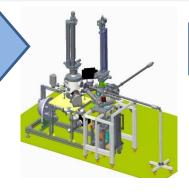


PHOTOCATHODE LAB - TIMELINE



06.2015 12.2015 03.2016

Photocathode Preparation and assembly of Transfersystem #1



1st CsK₂Sb photocathode for Gun 1.0



Fall 15

- Deposition studies
- Substrate preparation
- Set up transfer system 1

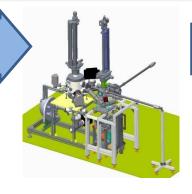
Spring 16

- Set up transfer system 2
- 1st CsK₂Sb photocathode for Gun 1.0



06.2015 12.2015 03.2016

Photocathode Preparation and assembly of Transfersystem #1



Fall 15

- Deposition studies
- Substrate preparation
- Set up transfer system 1

1st CsK₂Sb photocathode for Gun 1.0



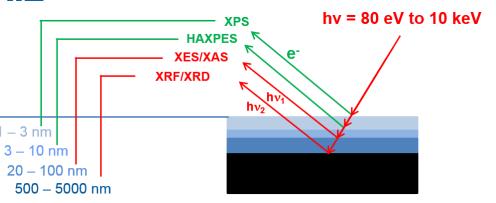
- Spring 16Set up transfer system 2
- 1st CsK₂Sb photocathode for Gun 1.0

UbERLinPro meets **©EMIL**

 Access to EMIL and technical apects under discussion

Unique methods combination Surface

 Resolve chemistry and crystal structure in-system Depth and for the same sample





THANK YOU FOR YOUR ATTENTION!

Many thanks to

- Julius Kühn, Thorsten Kamps
- Engineers: Petr Murcek (HZDR), Kerstin Martin, Daniel Böhlick
- Zihao Ding, John Smedley
- Susanne Schubert, Howard Padmore

REFERENCES



- [1] R. Barday et al., "Instrumentation Needs and Solutions for the Development of an SRF Photoelectron Injector at the Energy Recovery Linac bERLinPro", in *Proceedings of DIPAC 2011*, 2011.
- J. Völker et al., "Operational Experience with the Nb/Pb SRF Photoelectron Gun," in *Proceedings of IPAC 2012*, 2012, pp. 1518–1520.
- [3] M. A. H. Schmeißer et al., "Results from Beam Commissioning of an SRF Plug-gun Cavity Photoinjector," in *Proceedings of IPAC 2013*, 2013, pp. 282–284.
- [4] W. E. Spicer and A. Herrera-Gómez, "Modern Theory and Applications of Photocathodes," in *SPIE's* 1993 Interantional Symposium on Optics, Imaging and Instrumentation, 1993.
- [5] J. Smedley et al., "K2CsSb Cathode Development," AIP Conf. Proc. 1149, 18th Int. Spin Phys. Symp., pp. 1062–1066, 2009.
- [6] W. Spicer, "Photoemissive, Photoconductive, and Optical Absorption Studies of Alkali-Antimony Compounds," *Phys. Rev.*, vol. 112, no. 1, pp. 114–122, Oct. 1958.
- [7] S. Schreiber et al., "Photocathodes at FLASH," in *Proceedings of IPAC 2012*, pp. 625–627.
- [8] D. H. Dowell et al., "In situ cleaning of metal cathodes using a hydrogen ion beam," *Phys. Rev. Spec. Top. Accel. Beams*, vol. 9, no. 6, pp. 1–8, 2006.
- [9] D. H. Dowell and J. F. Schmerge, "Quantum efficiency and thermal emittance of metal photocathodes," *Phys. Rev. Spec. Top. Accel. Beams*, vol. 12, no. 7, p. 074201, Jul. 2009.
- [10] D. H. Dowell, "Sources of Emittance in Photocathode RF Guns: Intrinsic emittance, space charge forces, RF and solenoid effects," 2011.
- [11] K. L. Jensen, Advances in Imaging and Electron Physics: Electron Emission Physics. 2007.